

InSb - Indium Antimonide

Electrical properties

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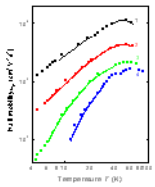
[Recombination Parameters](#)

Basic Parameters

Breakdown field	$\approx 10^3 \text{ V cm}^{-1}$
Mobility Electrons	$\leq 7.7 \cdot 10^4 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$
Mobility Holes	$\leq 850 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$
Diffusion coefficient Electrons	$\leq 2 \cdot 10^3 \text{ cm}^2 \text{s}^{-1}$
Diffusion coefficient Holes	$\leq 22 \text{ cm}^2 \text{s}^{-1}$
Electron thermal velocity	$9.8 \cdot 10^5 \text{ m s}^{-1}$
Hole thermal velocity	$1.8 \cdot 10^5 \text{ m s}^{-1}$

Mobility and Hall Effect

Electron Hall mobility versus temperature for different doping levels and different compensation ratios



Curve $N_d \text{ (cm}^{-3}\text{)}$ $\theta = N_a/N_d$

1. $3.85 \cdot 10^{14}$ 0.5
2. $8.5 \cdot 10^{14}$ 0.88
3. $9.5 \cdot 10^{14}$ 0.98
4. $1.35 \cdot 10^{15}$ 0.99

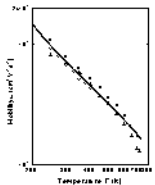
[\(Yaremko et al. \[1973\]\).](#)

Electron mobility versus temperature (high temperatures).

Solid line is theoretical calculation for electron-drift mobility.

Experimental data are Hall mobilities.

[\(Rode \[1971\]\).](#)

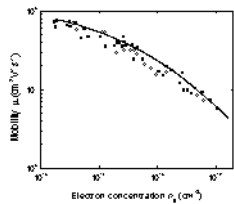


For pure *n*-InSb at $T \geq 200\text{K}$:

$$\mu_{nH} \approx 7.7 \cdot 10^4 (T/300)^{-1.66} \text{ (cm}^2 \text{V}^{-1} \text{s}^{-1}\text{)}.$$

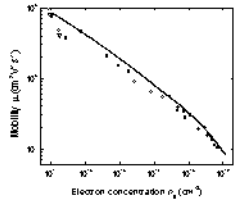
Electron mobility versus electron concentration. $T = 300 \text{ K}$

[\(Litwin-Staszewska et al. \[1981\]\).](#)



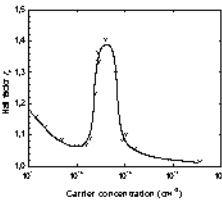
Electron mobility versus electron concentration. $T = 77 \text{ K}$

[\(Litwin-Staszewska et al. \[1981\]\).](#)



The electron Hall factor versus carrier concentration. $T = 77 \text{ K}$

[\(Baranskii and Gorodnichii \[1969\]\).](#)



Maximal electron mobility for pure n -InSb

$$77 \text{ K} \quad 1.2 \cdot 10^6 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$$

$$300 \text{ K} \quad 7.7 \cdot 10^4 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$$

Maximal electron mobility for InSb grown on GaAs substrate

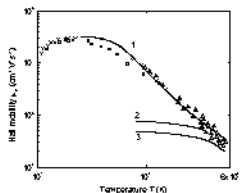
$$77 \text{ K} \quad 1.5 \cdot 10^5 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1} \quad (n_0 = 2.2 \cdot 10^{15} \text{ cm}^{-3})$$

$$300 \text{ K} \quad 7.0 \cdot 10^4 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1} \quad (n_0 = 2.0 \cdot 10^{16} \text{ cm}^{-3})$$

Maximal electron mobility for InSb grown on InP substrate

$$77 \text{ K} \quad 1.1 \cdot 10^5 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$$

$$300 \text{ K} \quad 7.0 \cdot 10^4 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$$



Hole Hall mobility versus temperature for different hole concentrations.

p_0 (cm^{-3}):

1. $8 \cdot 10^{14}$;

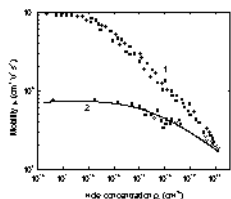
2. $3.15 \cdot 10^{18}$;

3. $2.5 \cdot 10^{19}$;

([Zimpel et al. \[1989\]](#)) and ([Filipchenko and Bolshakov \[1976\]](#)).

For pure p -InSb at $T > 60\text{K}$:

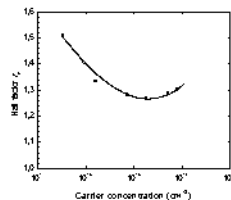
$$\mu_{\text{pH}} \approx 850(T/300)^{-1.8} \text{ (cm}^2 \text{V}^{-1} \text{s}^{-1}\text{)}$$



Hall mobility versus hole concentrations:

1. 77 K ([Filipchenko and Bolshakov \[1976\]](#));

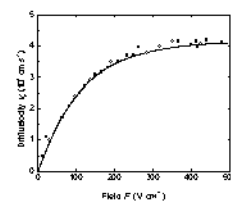
2. 290K ([Wiley \[1975\]](#)).



The hole Hall factor versus carrier concentration, 77 K

([Baranskii and Gorodnichii \[1969\]](#)).

Transport Properties in High Electric Fields

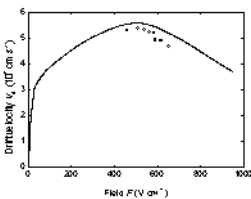


Field dependence of the electron drift velocity, 77 K.

Solid lines is the Monte Carlo calculation.

Points are experimental data.

([Asauskas et al. \[1980\]](#)).

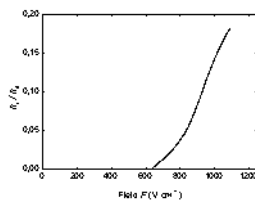


Field dependence of the electron drift velocity, 77 K.

Solid lines is the Monte Carlo calculation.

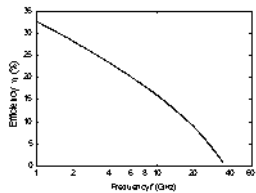
Points are experimental data.

([Neukermans and Kino \[1973\]](#)).



Fraction of electrons in the L-valley as a function of electric field F, 77K

([Asauskas et al. \[1980\]](#)).



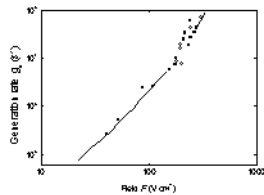
Frequency dependence of the efficiency in LSA mode

$$F_0 = F + F_1 \sin(2\pi \cdot f \cdot t)$$

$$F_0 = 2.5 \text{ kV cm}^{-1}$$

([Prokhorov et al. \[1977\]](#)).

Impact Ionization



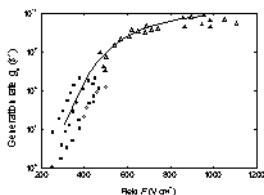
The dependence of generation rate for electrons g_n versus electric field F , 300 K

([Vorob'ev et al. \[1983\]](#)).

For 300 K, for $30 \text{ V/cm} < F < 300 \text{ V/cm}$:

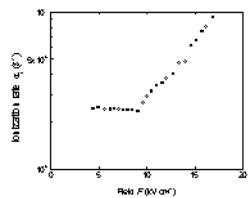
$$g_n(F) = 126 \cdot F^2 \exp(F/160) \text{ (s}^{-1}\text{)},$$

where F is in V cm^{-1} .



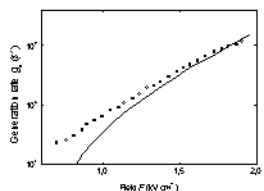
The dependence of generation rate for electrons g_n versus electric field F , 77 K

([Krotkus and Dobrovolskis \[1988\]](#)) and ([Vorob'ev et al. \[1988\]](#)).



The dependence of ionization rates for electrons α_1 versus the electric field F , $T=78 \text{ K}$

([Gavrushko et al. \[1978\]](#)).



The dependence of generation rate for holes g_p versus the electric field F , $T = 77 \text{ K}$

([Adomaitis et al. \[1985\]](#)).

Recombination Parameters

For pure InSb at $T \geq 250 \text{ K}$ lifetime of carrier (electrons and holes) is determined by Auger recombination:

$$\tau_n = \tau_p \approx 1/C n_i^2,$$

where $C \approx 5 \cdot 10^{-26} \text{ cm}^{-6} \text{ s}^{-1}$ is the Auger coefficient.

n_i is the intrinsic carrier concentration.

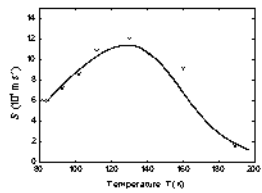
For $T = 300 \text{ K}$

$$\tau_n = \tau_p \approx 5 \cdot 10^{-8} \text{ s}$$

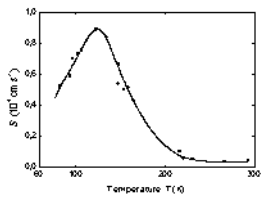
For $T = 77 \text{ K}$

$$n\text{-type: the lifetime of holes} \quad \tau_p \sim 10^{-6} \text{ s}$$

$$p\text{-type: the lifetime of electrons} \quad \tau_n \sim 10^{-10} \text{ s}$$



Temperature dependence of surface recombination velocity for *p*-InSb.
([Euthymiou et al. \[1981\]](#)).



Temperature dependence of surface recombination velocity for *n*-InSb.
([Skountzous and Euthymiou \[1976\]](#)).

Radiative recombination coefficient $\sim 5 \cdot 10^{-11} \text{ cm}^3 \text{ s}^{-1}$

Auger coefficient $\sim 5 \cdot 10^{-26} \text{ cm}^6 \text{ s}^{-1}$

